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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/768,940	01/30/2004	Kei Arao	51890	7175
75	90 12/27/2005		EXAMINER	
EDWARDS & ANGELL, LLP			WALKE, AMANDA C	
P.O. Box 55874 Boston, MA 02205			ART UNIT PAPER NUMBER	
Boston, Will	,2203		1752	

DATE MAILED: 12/27/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/768,940	ARAO ET AL.					
Office Action Summary	Examiner	Art Unit					
	Amanda C. Walke	1752					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period was precised to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin fill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this cor D (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on <u>06 Octoor</u> 2a) This action is FINAL . 2b) This 3) Since this application is in condition for allower closed in accordance with the practice under Expression in the practice of	action is non-final. nce except for formal matters, pro		merits is				
Disposition of Claims							
4) ☐ Claim(s) 1 and 3-10 is/are pending in the application 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1 and 3-10 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	vn from consideration.						
Application Papers							
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Examine 10.	epted or b) objected to by the I drawing(s) be held in abeyance. See ion is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CF					
Priority under 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal F 6) Other:	ate	-152)				

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DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1, and 3-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kiuchi et al (EP 1142923) in view of Smith et al (4,231,951) or Kundsen et al (5,262,280).

Kiuchi et al disclose a flame-retardant epoxy resin composition, and a semiconductor device made therefrom. The composition is prepared from an epoxy resin and 2 phenolic resins are demonstrated in Comp. Ex. 10 (page 23). Phenolic resin 2 employed in that composition is a:phenol-biphenylaralkyl. The Kiuchi et al reference

Smith et al disclose a photoinitiator that is taught to be useful in (photo) curable epoxy resins.

Knudsen et al disclose a curable composition comprising a photoinitator and an epoxy resin.

Given the teachings of the references, it would have been obvious to one of ordinary skill in the art to prepare the material of Kiuchi et al choosing to employ a photoinitiator to aid in the polymerization and curing of the resin layer as taught to be conventional by either Smith et al or Knudsen et al in the place of the curing agent.

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3. Claims 1 and 3-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kiuchi et al (6,730,402 or 2003/0152776) in view of Smith et al (4,231,951) or Kundsen et al (5,262,280).

Kiuchi et al disclose a flame-retardant epoxy resin composition, and a semiconductor device made therefrom. The composition is prepared from an epoxy resin and a phenol-biphenylaralkyl. The resin also comprises an alkoxylated melamine.

Smith et al and Knudsen et al have been discussed above.

Given the teachings of the references, it would have been obvious to one of ordinary skill in the art to prepare the material of Kiuchi et al choosing to employ a photoinitiator to aid in the polymerization and curing of the polymers layer as taught to be conventional by either Smith et al or Knudsen et al in the place of the curing agent.

Furthermore, it is the position of the examiner that the resin prepared from the teachings of the references that is employed in a semiconductor device manufacturing method would comprise the same components as the instantly claimed resist, and thus is a negative resist layer.

Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Cited as being similar materials to those instantly claimed are: Knudsen et al (5, 366, 846), Lamanna et al (5,514,728), Tzou (5,858,618), and Janke et al (5,877,229).

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Amanda C. Walke whose telephone number is 571-272-1337. The examiner can normally be reached on M-R 5:30-4.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Cynthia Kelly can be reached on 571-272-1526. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Amanda C Walke Examiner

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ACW December 22, 2005